


|  |  |   |
|--|--|---|
| <b>Search Notes</b><br> | <b>Application/Control No.</b><br>10763224 | <b>Applicant(s)/Patent Under Reexamination</b><br>CHO, BYOUNG-WOO |
|  | <b>Examiner</b><br>Haney, Richale L.       | <b>Art Unit</b><br>3765   |

| SEARCHED |  |            |          |
|----------|--|------------|----------|
| Class    | Subclass   | Date       | Examiner |
| 2        | 181, 195.1                                       | 08/03/2006 | RLH      |
| above    | updated  | 2/2/2007   | RLH      |
| above    | updated  | 9/30/2008  | RLQ      |
| 2        | 171, 195.3, 209.12, 195.2, 181.4, 209.3, dig. 11 | 9/30/2008  | RLQ      |

| SEARCH NOTES             |                  |          |
|--------------------------|------------------|----------|
| Search Notes             | Date             | Examiner |
| See EAST search printout | 08/03/2006update | RLH      |
| See EAST search printout | 9/30/2008        | RLQ      |

| INTERFERENCE SEARCH |          |      |          |
|---------------------|----------|------|----------|
| Class               | Subclass | Date | Examiner |
|                     |          |      |          |

|  |  |
|--|--|
|  |  |
|--|--|